

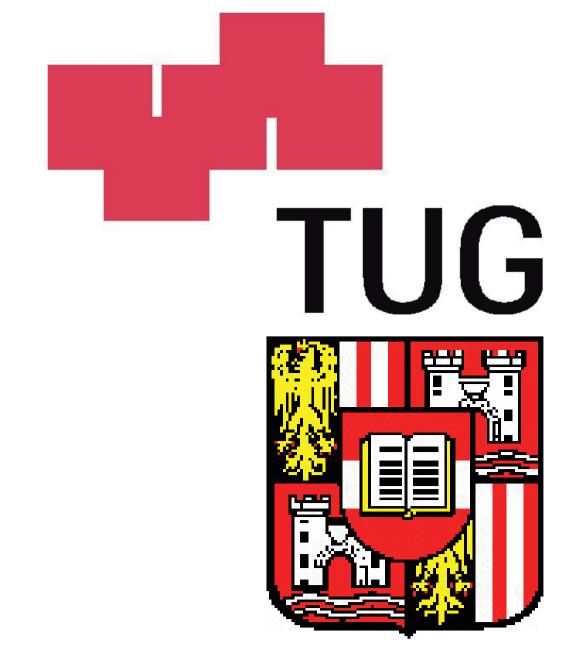
Spontaneous rearrangement of para-sexiphenyl crystallites into nano-fibers

G. Hlawacek¹, C. Teichert¹,

A. Andreev^{1,2,4}, H. Sitter²,

H. Plank³, R. Resel³, P. Frank³, A. Winkler³

- 1) Institute of Physics, University of Leoben, A-8700 Leoben, Austria
- 2) Institute for Semiconductor and Solid State Physics, University of Linz, A-4040 Linz, Austria
- 3) Institute for Experimental Physics, University of Graz, A-8010 Graz, Austria
- 4) present address: Nanoident Technologies AG, A-4020 Linz, Austria



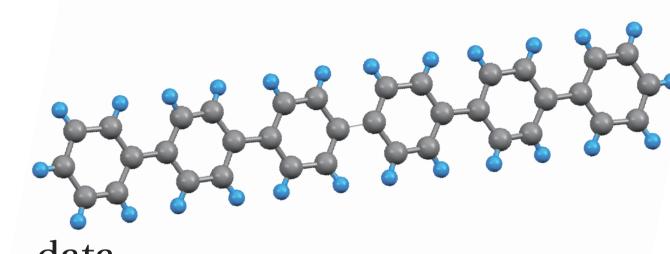
Motivation

Para-sexiphenyl (6P) is an organic, optical active semiconductor with potential for a variaty of applications. A high degree of control over the growth process is necessary to fabricate device quality layers.

Here, we report on an atomic force microscopy study on the spontaneous formation of high aspect ratio crystallite chains. The internal structure of these chains -- which is related to the crystallites formed during the intial growth stage -could be revealed. A statistical analysis of chain dimensions together with thermal desorption spectroscopy and x-ray data allows to explain the spontaneous formation process.

Experimental

para-sexiphenyl

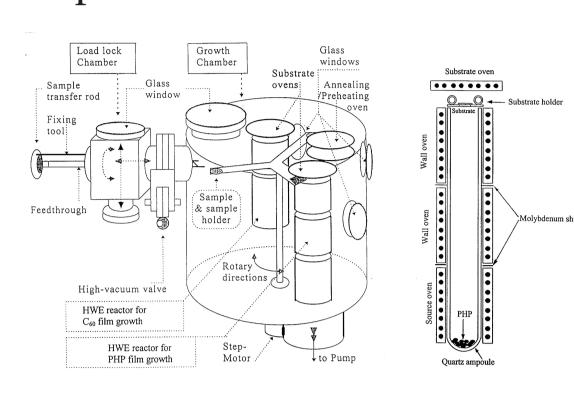


data

- monoclinic in P2_{1/c} space group - herringbone type bulk structure
- -a = 0.809 nm, b = 0.557 nm, $c = 2.624 \text{ nm}, \ \beta = 98.17^{\circ}$
- * molecule length: 26.3 Å
- * molecule width: 4.3 Å

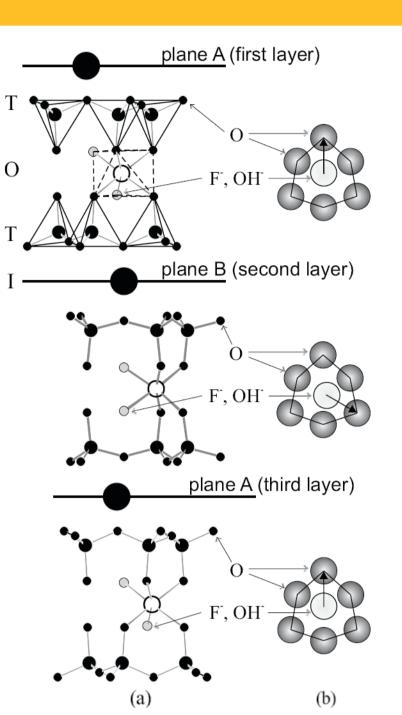
Hot Wall Epitaxy

Deposition temperature: 90°C Base pressure: 1x10⁻⁶ mbar Source temperature: 240°C Wall temperature: 260°C Deposition rate: ~2 nm/min



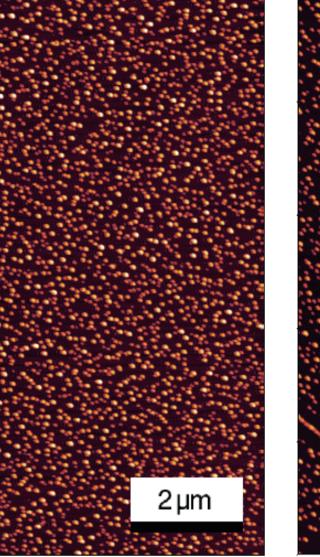
mica(001)

The mica(001) surface used is a cleavage plane of 2M₁- o muscovite with the formula _T $KAl_2(AlSi_3)O_{10}(OH,F)_2$. Due to charge repulsion between the oxygen in the top most layer the anions are displaced from the center of the hexagonal opening - which leads to a twofold symmetry of mica(001).

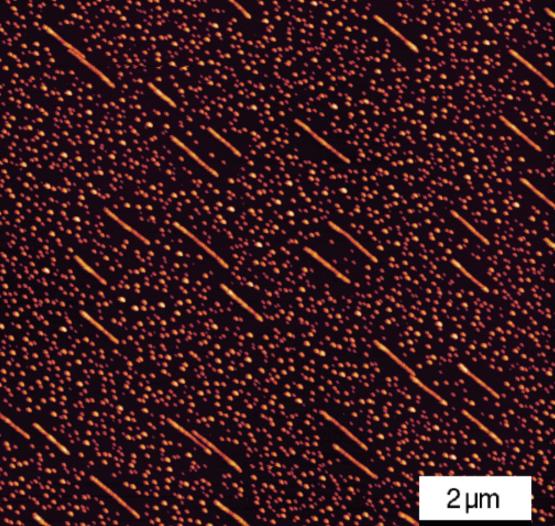


Early growth stage

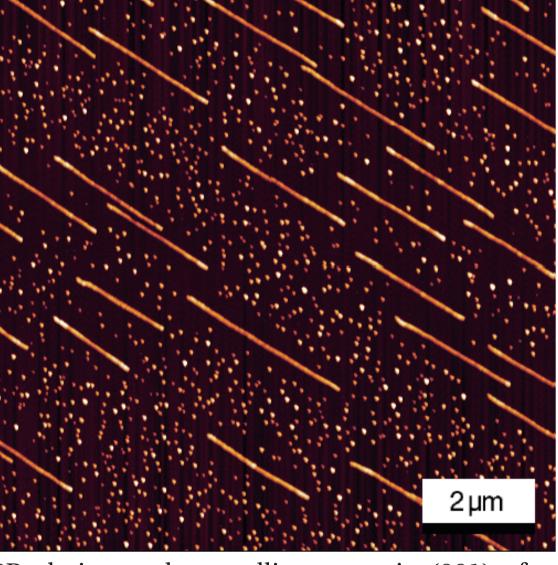
Intermediate growth stage



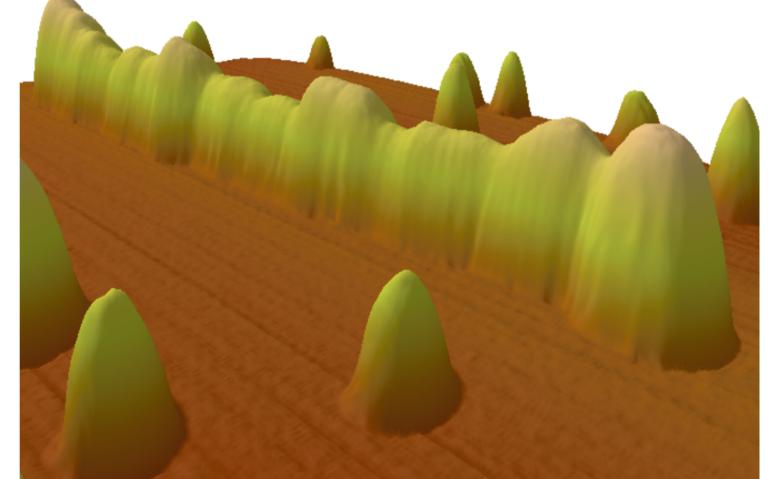
6P crystallites on mica(001) after 30 sec of deposition. w=50 nm, l=100 nm, and h=10 nm.



6P chains and crystallites on mica(001) after 6P chains and crystallites on mica(001) after 45 s of deposition. Chain length 1µm.

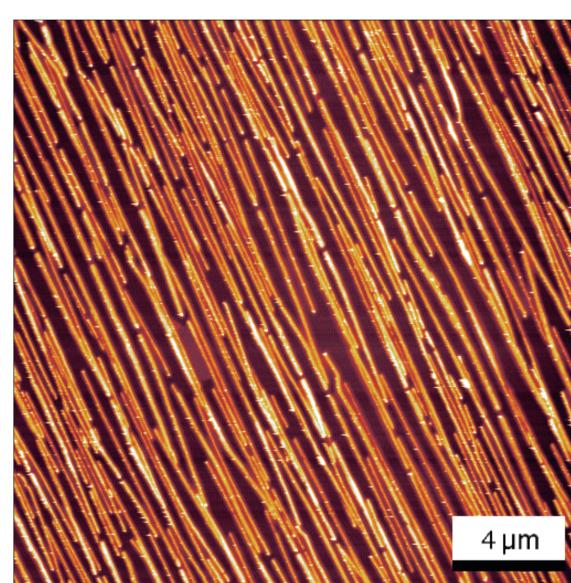


55 s of deposition. Chain length $> 2 \mu m$.



35 seconds 45 seconds 50 seconds 55 seconds

Final growth stage



6P chains and crystallites on mica(001) after 55 s of deposition. Chain length $> 2 \mu m$.

No crystallites on the mica surface, but the whole surface is covered by parallel running large aspect ratio chains.

Two 120° rotated domains exist due to the alignment of

More crystallites can be found on top of existing chains.



Evolution of crystallite size with ongoing deposition.

Crystallites of uniform size are formed during the first 30 s of deposition.

Formation parallel, onedimensional chains after 35 s with uniform length distribution and a threshold length With ongoing deposition:

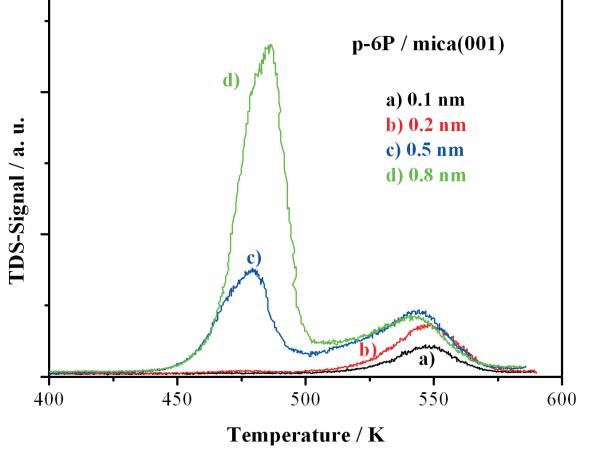
- Av. chain length increases

- Min. chain length increases
- Length distribution broadens
- due to coalescence
- Width and height change slowly Chains have internal structure. The size of the chain segments is equal to the size of the crystallites.

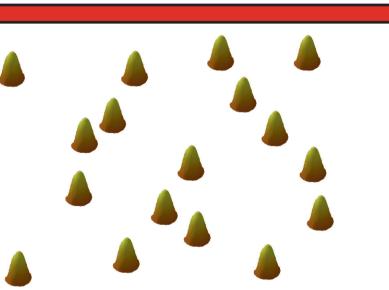
chain length [µm]

Growth scenario

A denuded zone exists around the chains which is free of crystallites. The lower rectangle holds sufficient crystallites to form a chain with the same length as in the upper rectangle.



desorption spectra of 6P mica(001) for different film thickness. The monolayer peak at 550 K saturates around 0.5 nm film thickness. This corresponds to a single layer of lying molecules.



randomly distributed crystallites

2µm

formed where a defect exists but no new defects are formed.

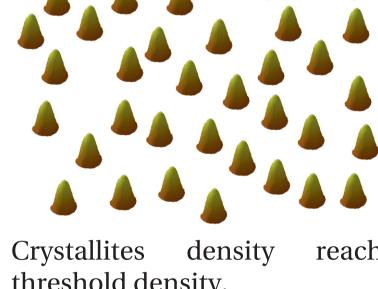
(a) 6P chains as grown. The green dashed lines indicate the

position of the proposed defects in the wetting layer. (b) After

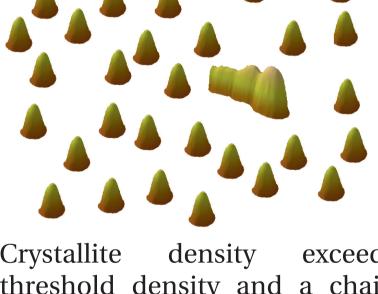
annealing the chain length has increased. New chains are only

three

missaligned



reaches threshold density.



Crystallite threshold density and a chain starts to form.



The chain is long enough to reduce the crystallite density below the threshold density.

Chain formation

Stage 1

Formation of crystallites with uniform size on a wetting layer of lying molecules.

Stage 2

Above a critical density the crystallites regroup as entites using defects in the wetting layer as seeds. This reduces the stress in the wetting layer -> new crystallites can form.

Stage 3

The whole surface is covered by chains.

References

Teichert, C. et al., Appl. Phys. A 82, 665-669 (2006)

Plank, H., et al., Thin Solid Films 443, 108-114

(2003)

Summary

The growth of 6P on mica(001) can be split into three stages:

During the **intial growth stage** small crystallites are formed on top of a wetting layer. Both are formed of lying molecules.

With increasing crystallite density the strain fields induced by the crystallites into the wetting layer start to overlap.

To **reduce the strain**, defects in the wetting layer act as **seeds for the formation** of crystallite chains.

The formed chains are oriented with respect to the mica(001) surface and have a narrow length distribution.

This chains are formed by crystallites -which roughly contain 140000 mocules -as entities.

Contact

Gregor Hlawacek (gregor.hlawacek@unileoben.ac.at)

Christian Teichert (teichert@unileoben.ac.at) Institute of Physics

University of Leoben, 8700 Leoben, Austria web: http://www.unileoben.ac.at/~spmgroup/ Supported by Austrian Science Fund Project S9707-N08

